## **HPLC Application** ID No.: **25436**



Products used in this application:

Gemini<sup>®</sup>

## GenX replacement PFOA compound by LC-MS/MS

Gemini® 3 µm C18 110 Å, LC Column 50 x 2 mm, Ea

50 x 2 mm ID **Dimensions:** Order No: 00B-4439-B0 **Elution Type:** Gradient

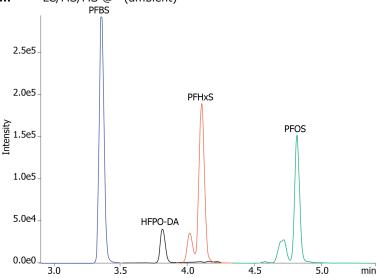
Eluent A: 20mM Ammonium Acetate in Water

Eluent B: Methanol

Gradient	Step No.	Time (min)	Pct A	Pct B
Profile:	1	0	95	5
	2	0.1	45	55
	3	4.5	1	99
	4	8	1	99
	5	8.5	95	5

Flow Rate: 0.6 mL/min Col. Temp.: 40 °C

**Detection:** LC/MS/MS @ (ambient)



#### **ANALYTES:**

**PFBS** 

Retention Time: 3.4 min

**PFBS** 

Retention Time: 3.4 min

HFPO-DA

Retention Time: 3.7 min

HFPO-DA

Retention Time: 3.7 min

13C3-HFPO-DA

Retention Time: 3.7 min

**PFHxS** 

Retention Time: 4.1 min

**PFHxS** 

Retention Time: 4.1 min

**PFOS** 

Retention Time: 4.7 min

**PFOS** 

Retention Time: 4.7 min

www.phenomenex.com

©2025 Phenomenex Inc. All rights reserved.

Phenomenex products are available worldwide.

For more information contact your Phenomenex Representative at support@phenomenex.com

# Sample Preparation Details for HPLC Application ID No.: 25436



## GenX replacement PFOA compound by LC-MS/MS

#### **PRODUCT DESCRIPTION:**

**Condition:** 

Strata GCB, 500mg/6mL, 30/Pk

Order No.: 8B-S528-HCH

### **SOLID PHASE EXTRACTION (SPE) PRODCEDURE:**

Note: The solvent volumes shown below are for a bed mass.

Inject: 10 µL on HPLC LC/MS/MS @ (ambient)

The solvent volumes will need to be adjusted for a smaller or larger bed mass.

.oac	l <b>:</b>
Vas	h:
Ory:	
lut	<u>e:</u>
ina	Prep and Analysis:
	All standards including HFPO-DA and its stable isotope labelled surrogate 13C3-HFP

ANALYTES:		Spiked Conc. (ng/mL)	Log P	pKa	% Rec	%RSC (n=0)
1	PFBS	0				
2	PFBS	0				
3	HFPO-DA	0				
4	HFPO-DA	0				
5	13C3-HFPO-DA	0				
6	PFHxS	0				
7	PFHxS	0				
8	PFOS	0				

0

This method is designed as a convenient starting point for further investigation and can be tailored to meet your extraction goals. Call your local Phenomenex Representative for assistance in method development and optimization techniques.

©2025 Phenomenex Inc. All rights reserved.

PFOS

For more information contact your Phenomenex Representative at support@phenomenex.com

